



IFW

## PATENT APPLICATION

### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q81007

Yasushi OKUBO, et al.

Appln. No.: 10/820,785

Group Art Unit: 1756

Confirmation No.: 8719

Examiner: Stephen D. ROSASCO

Filed: April 9, 2004

For: METHOD OF MANUFACTURING A PHOTOMASK, AND PHOTOMASK BLANK

### RESPONSE TO RESTRICTION REQUIREMENT

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This responds to the Restriction Requirement, dated November 6, 2006. In response to the Restriction Requirement, Applicant elects Group I, claims 1-24 for examination. This election is made without traverse.

Applicant reserves the right to file a Divisional Application directed to non-elected claims 25-29.

The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account.

Respectfully submitted,

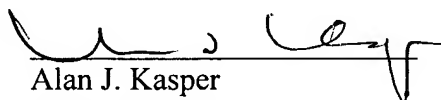
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WASHINGTON OFFICE

**23373**

CUSTOMER NUMBER

Date: December 4, 2006

  
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Registration No. 25,426